

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Art Unit

: 1752

Examiner

: Barbara Lee Gilliam

Serial No.

: 09/890,926

Filed

: August 7, 2001: Shinji Tanaka

Inventors

Vatauhira Hebar

Title

: Katsuhiro Uehara : PHOTOSENSITIVE RESIN

: PRINT PLATE MATERIAL

: AND PRODUCTION METHOD

: FOR PHOTOSENSITIVE

: RESIN PRINT PLATE

RECEIVED JUN 18 2003 TC 1700

Docket No.: 1265-01

Confirmation No.: 1861

Dated: June 11, 2003

## **AMENDMENT**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated December 13, 2002, Applicants amend as follows:

## In the Specification

Kindly amend the specification as follows:

## Page 2, third paragraph bridging page 3, kindly replace as follows:

Concretely, proposed are <u>method</u> (1) <u>which is</u> a method of forming an image on a photosensitive resin layer or on a thin film layer provided on a photosensitive resin layer, with toner or liquid ink, not requiring an original picture film (Japanese Patent Publication No. 20029/1983, Japanese Patent Laid-Open Nos. 110164/1991, 10709/1998, 10710/1998); <u>method</u> (2) <u>which is</u> a method of directly obtaining a printing plate by exposing a porous material or a photosensitive layer to laser rays followed by dissolving or subliming the exposed part (Japanese Patent Laid-Open Nos. 56601/1977, 127005/1978, Japanese Patent Publication No. 40033/1981,

 $\int_{\mathcal{C}} f$